

	Type	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors	Ref #
104	BRS	0	semiconductor with diffuse\$3 with (hydrogen or h2 or "h.sub.2") with saturat\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/12 01:50				S108
105	BRS	16	semiconductor and diffuse\$3 with (hydrogen or h2 or "h.sub.2") with saturat\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/12 02:03				S109
106	BRS	21	("4084986" "4467519" "4762801" "4824799" "5024957" "5110757" "5139959" "5252143" "5296391" "5356830").PN. OR ("5420053").URPN.	US-PGPUB; USPAT; USOCR	2006/04/12 01:59				S110
107	BRS	5	semiconductor and diffus\$5 with (hydrogen or h2 or "h.sub.2") with saturat\$5 with anneal\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:09				S111

	Type	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors	Ref #
108	BRS	5	semiconductor and diffus\$5 with (hydrogen or h2 or "h.sub.2") with saturat\$5 with (anneal\$4 or heat\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/12 16:09				S112
109	IS&R	2	("20010044205").PN	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/12 16:12				S114
110	BRS	13	alumina adj alox	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/12 16:15				S120
111	IS&R	2	("5530293").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:18				S121
112	IS&R	2	("5100817").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:20				S122
113	IS&R	2	("4920044").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:36				S123

	Type	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors	Ref #
114	IS&R2		("5888839").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:41				S124
115	IS&R2		("5793110").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:47				S125
116	IS&R2		("5750403").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:50				S126
117	IS&R2		("4920077").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/14 14:53				S128

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
1	BRS	L1	8	aluminum adj annealing with (hydrogen or h2 or "h.sub2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:06			
2	BRS	L2	1	(438/622).ccls. and (h2 or hydrogen) near diffus\$5 with semiconductor and (planariz\$ or hsq or sog)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:42			
3	BRS	L7	1	(438/622).ccls. and (h2 or hydrogen or "h.sub.2") with diffus\$5 same (planariz\$ or hsq or sog or teos)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:45			
4	BRS	L9	2	(438/622).ccls. and (h2 or hydrogen or "h.sub.2") with diffus\$5 with (anneal\$4 or trat\$5) and (planariz\$ or hsq or sog or teos or cmp)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:48			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
5	BRS	L11	0	(438/660).ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5) and (planariz\$ or hsq or sog or teos or cmp)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:48			
6	BRS	L12	2	("438"/\$).ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5) and (planariz\$ or hsq or sog or teos or cmp)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:50			
7	BRS	L13	2	("257"/\$).ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5) and (planariz\$ or hsq or sog or teos or cmp)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:50			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
8	BRS	L16	0	("257"/E21.279) .ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:51			
9	BRS	L17	1	("257"/E21.614) .ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:51			
10	BRS	L15	13	("438"/\$).ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:52			
11	BRS	L14	16	("257"/\$).ccls. and (h2 or hydrogen or "h.sub.2") with saturat\$4 with (anneal\$4 or trat\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/04/16 02:55			